



I HEREBY CERTIFY THAT THIS CORRESPONDENCE IS BEING DEPOSITED WITH THE UNITED STATES POSTAL SERVICE AS FIRST CLASS MAIL IN AN ENVELOPE ADDRESSED TO: COMMISSIONER for PATENTS, P. O. Box 1450, Arlington, VA 22313-1450.

8/19/03  
(Date of Deposit)

Karen Cinq-Mars (Signature & Date)

*Karen Cinq-Mars* 8/19/03

#16  
100  
950

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In Re Application of \_\_\_\_\_ :

August 19, 2003

Caroline Boulenger \_\_\_\_\_ :

Art Unit: 2822

Serial No. 09/756,997 \_\_\_\_\_ :

Examiner: Christy L. Novacek

Filed: January 8, 2001 \_\_\_\_\_ :

IBM Corporation  
Dept. 18G/Bldg. 300-482  
2070 Route 52,  
New York 12533-6531

Title: METHOD FOR ELIMINATING  
DEVELOPMENT RELATED DEFECTS  
IN PHOTORESIST MASKS \_\_\_\_\_ :

RECEIVED  
AUG 26 2003  
TECHNOLOGY CENTER 2800

**SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT**

Commissioner for Patents  
P. O. Box 1450  
Arlington, Va 22313-1450

Sir:

Pursuant to the duty of disclosure set forth in 37 CFR 1.56, and further pursuant to 37 CFR 1.97 and 37 CFR 1.98, Applicants hereby respectfully submit copies of the following documents as listed on Form PTO-1449, attached hereto.

Please charge any fees in connection with this statement to Deposit Account # 09-0458.

Respectfully submitted,

*Joseph P. Abate* 8-19-03  
Joseph P. Abate, Attorney  
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JPA/kcm

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